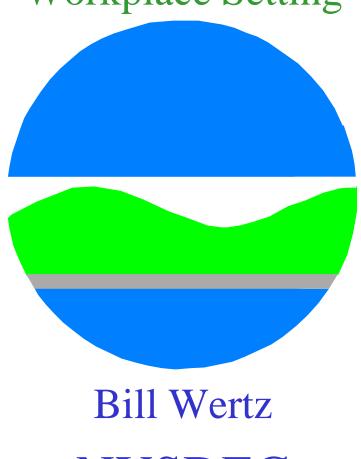
RCRA EI Challenges

Conflicting Exposure Standards in the Workplace Setting

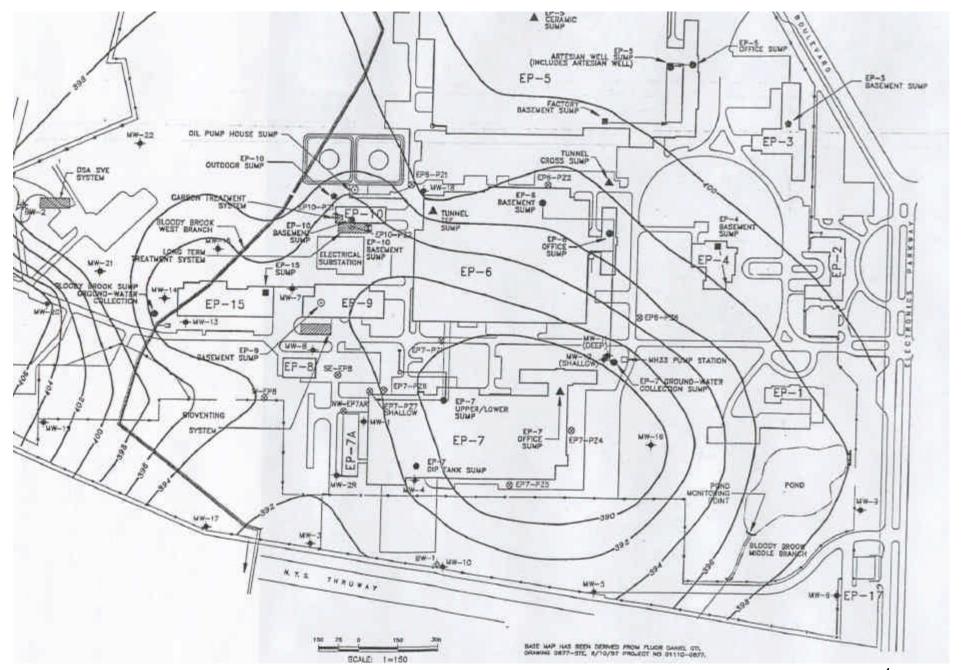


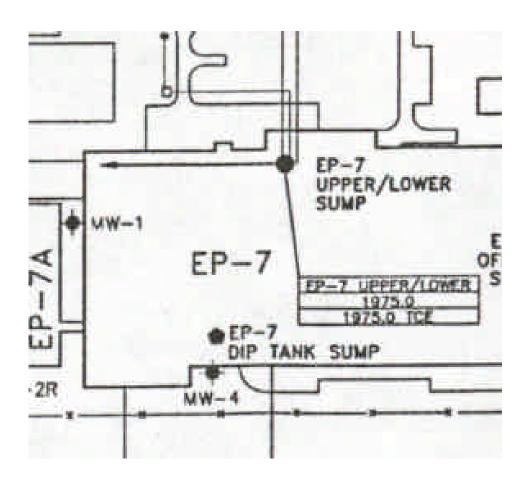
NYSDEC

Workplace Exposures from Groundwater Contamination

Lockheed Martin Electronics Park Facility

- Constructed in the mid-1940's by the General Electric (GE) Company
- Electronic components were manufactured in the past. Presently sonar and radar systems are manufactured
- Constituents of concern in groundwater include: trichloroethene, 1,2,dichloroethene, and vinyl chloride







Chemical	Indoor Air Concentration in basement
Trichloroethylene	58 ppbv

• Based on basement air results, DEC requested additional indoor air samples in office settings.

LMC Indoor Air Sampling Results	
Location	Result (ppbv)
Field Programs Office EP 7	19
Towed Array Area EP 6	2.3
Conference Room EP 6	ND(.4)
MTM Office EP 5	ND(.4)
Govt Properties Office EP 7	ND(.4)
Outside Background	ND(.4)
RAT Test Area EP 5	2.7

Chemical	Target Indoor Air Concentration to Satisfy Both the Prescribed Risk Leveland the Target Hazard Index [R=10 ⁻⁵ , HI=1] From: Table 1, USEPA Draft Vapor Intrusion Guidance, 10/2001
Trichloroethylene	1.10ppbv

The EI Quandary

- Workplace indoor air concentrations are above the guideline levels, but way below (> 3 orders of magnitude) the OSHA PEL of 100 ppm.
- Company unwilling to take actions to reduce impacts due to groundwater - concerned with implications for other workplace related exposures.

NYSDEC Response

- Company was requested to take actions to reduce exposures related to groundwater.
- Company required to notify employees of exposure.
- EI 725 = yes